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(12) **United States Design Patent**
Ono

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(54) **APERTURE ADJUSTING DEVICE**

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(**) Term: **15 Years**

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(30) **Foreign Application Priority Data**

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(51) **LOC (11) Cl.** **16-06**

(52) **U.S. Cl.**
USPC **D16/134; D16/219**

(58) **Field of Classification Search**
USPC D16/130, 134, 136, 200-220, 235, 237
CPC G02B 5/00; G03B 11/04; G03B 17/00;
G03B 17/02; G03B 9/08
See application file for complete search history.

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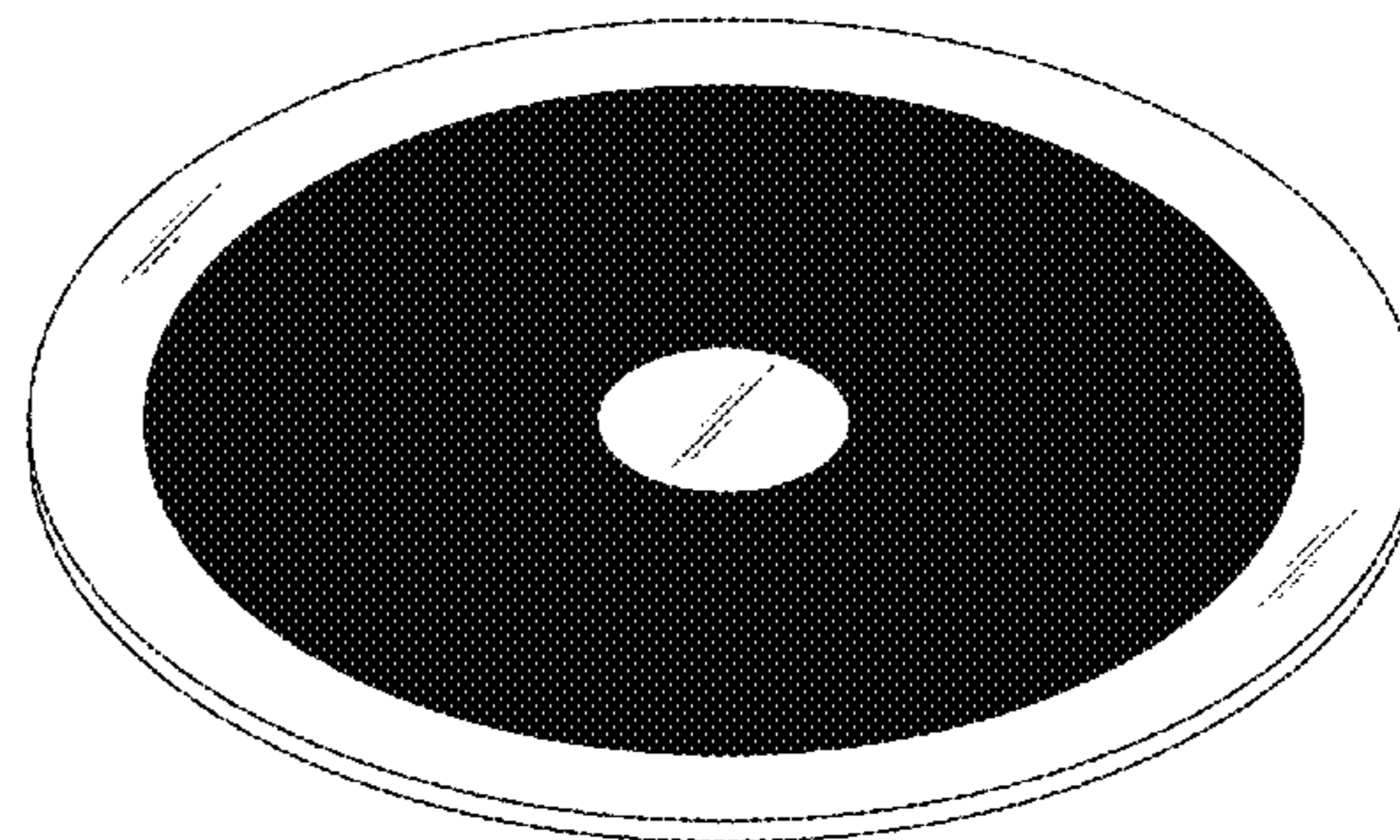
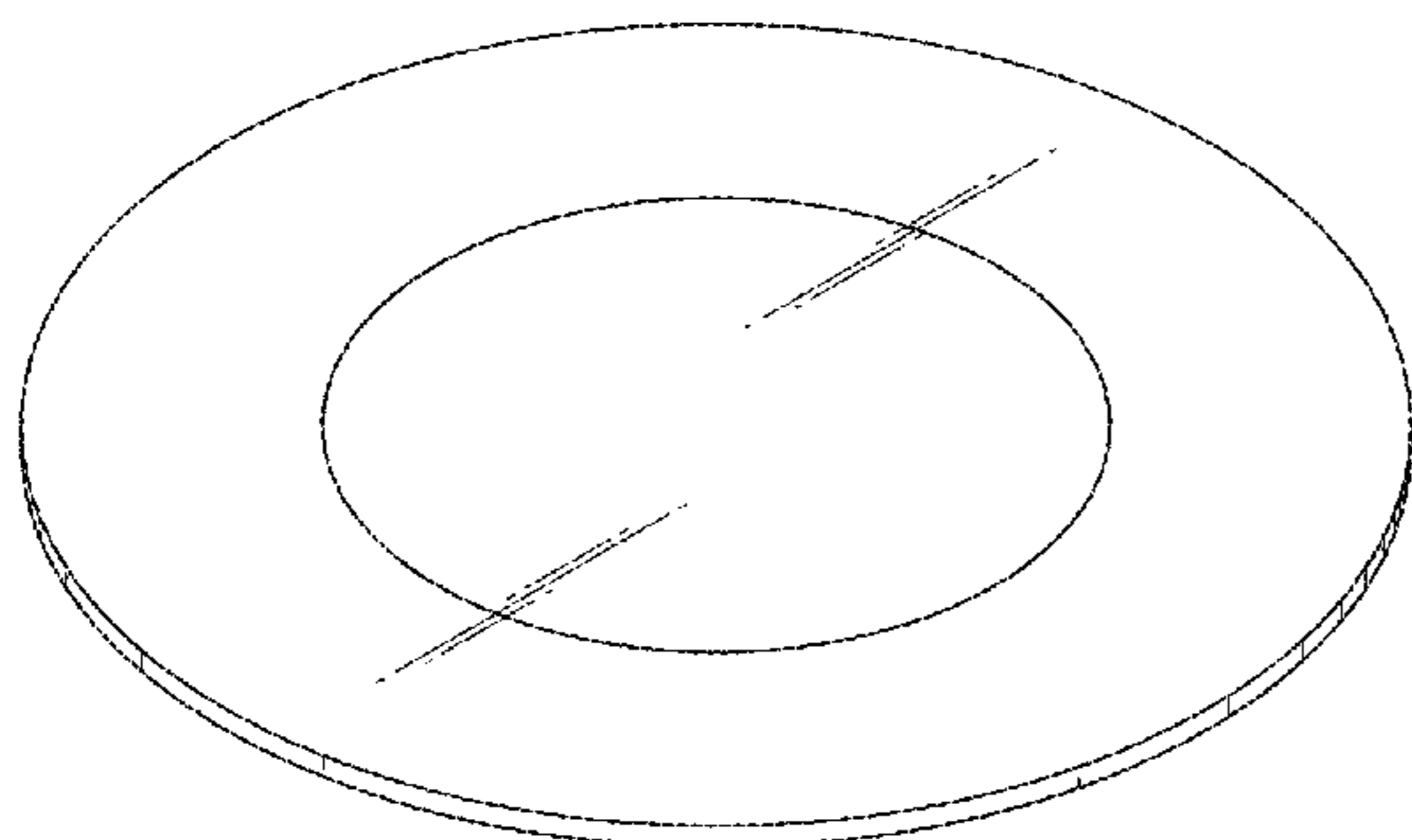
(57) **CLAIM**

The ornamental design for an aperture adjusting device, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of an aperture adjusting device showing our new design;
FIG. 2 is a front view thereof, the rear view is identical image;
FIG. 3 is a top plan view thereof, the bottom plan view is identical image;
FIG. 4 is a right side view thereof, the left side view is identical image;
FIG. 5 is a perspective view of the aperture adjusting device showing a state in which the shield area is maximum;
FIG. 6 is a front view of the aperture adjusting device showing a state in which the shield area is maximum;
FIG. 7 is a front view showing changing state of the shield area between the state of FIG. 2 and the state of FIG. 6; and,
FIG. 8 is a front view showing changing state of the shield area between the state of FIG. 2 and the state of FIG. 6.

1 Claim, 4 Drawing Sheets



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FIG. 1

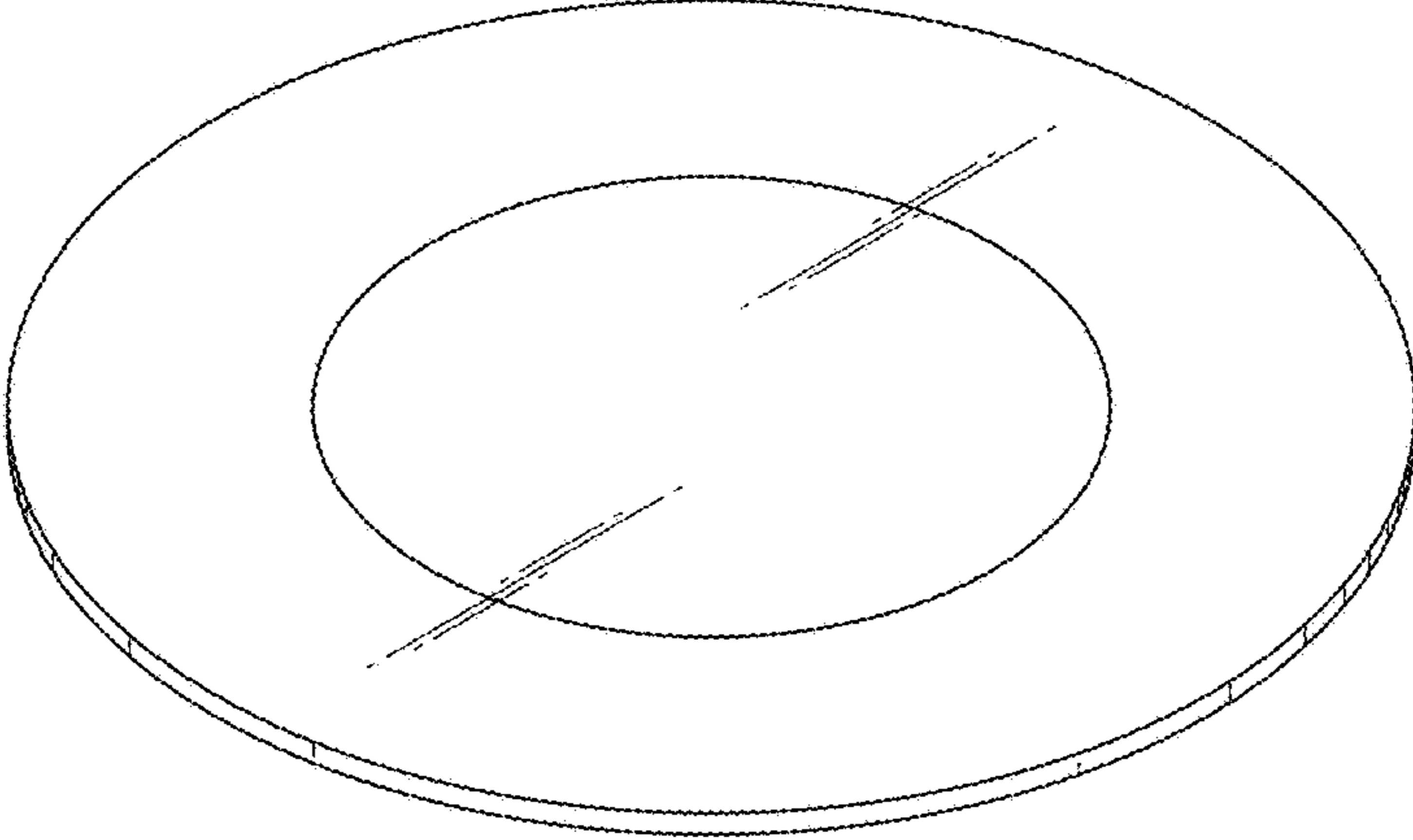


FIG. 2

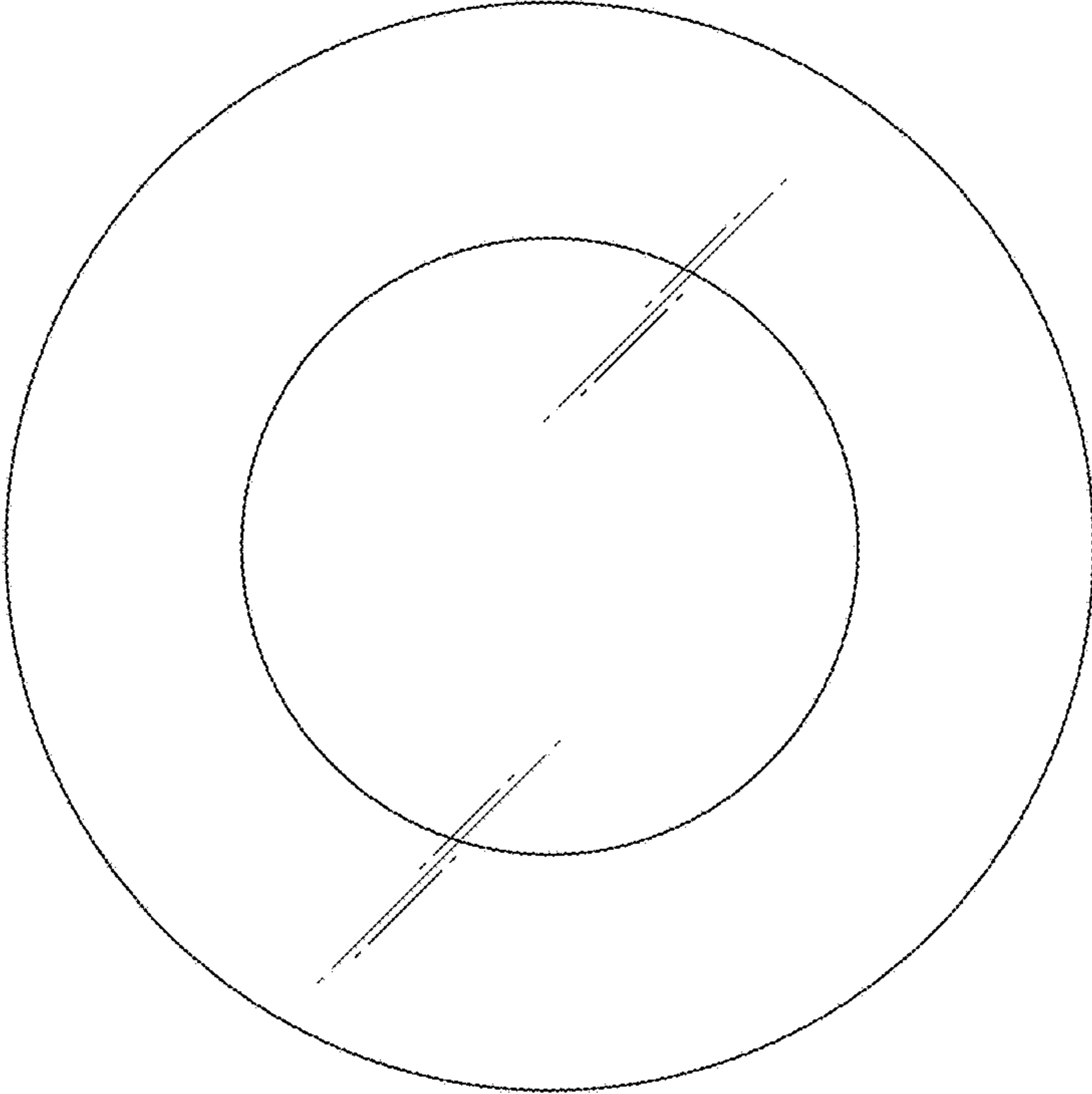


FIG. 3

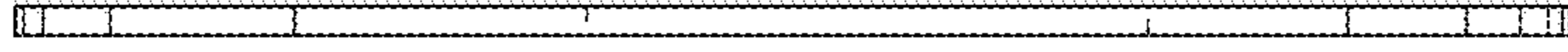


FIG. 4

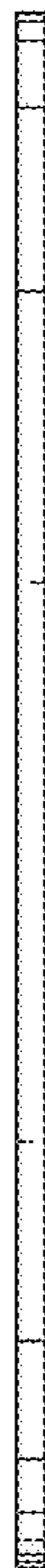


FIG. 5

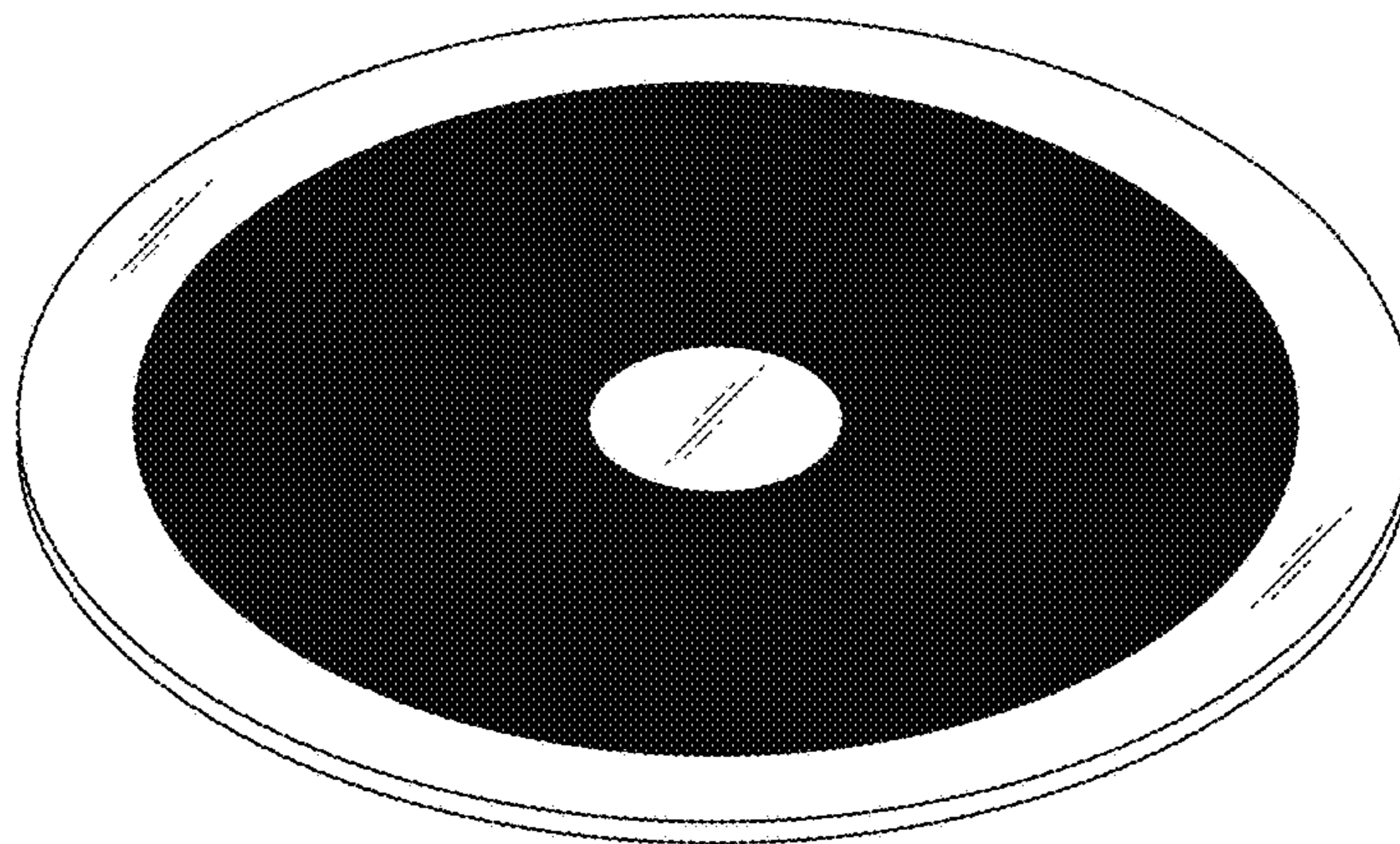


FIG. 6

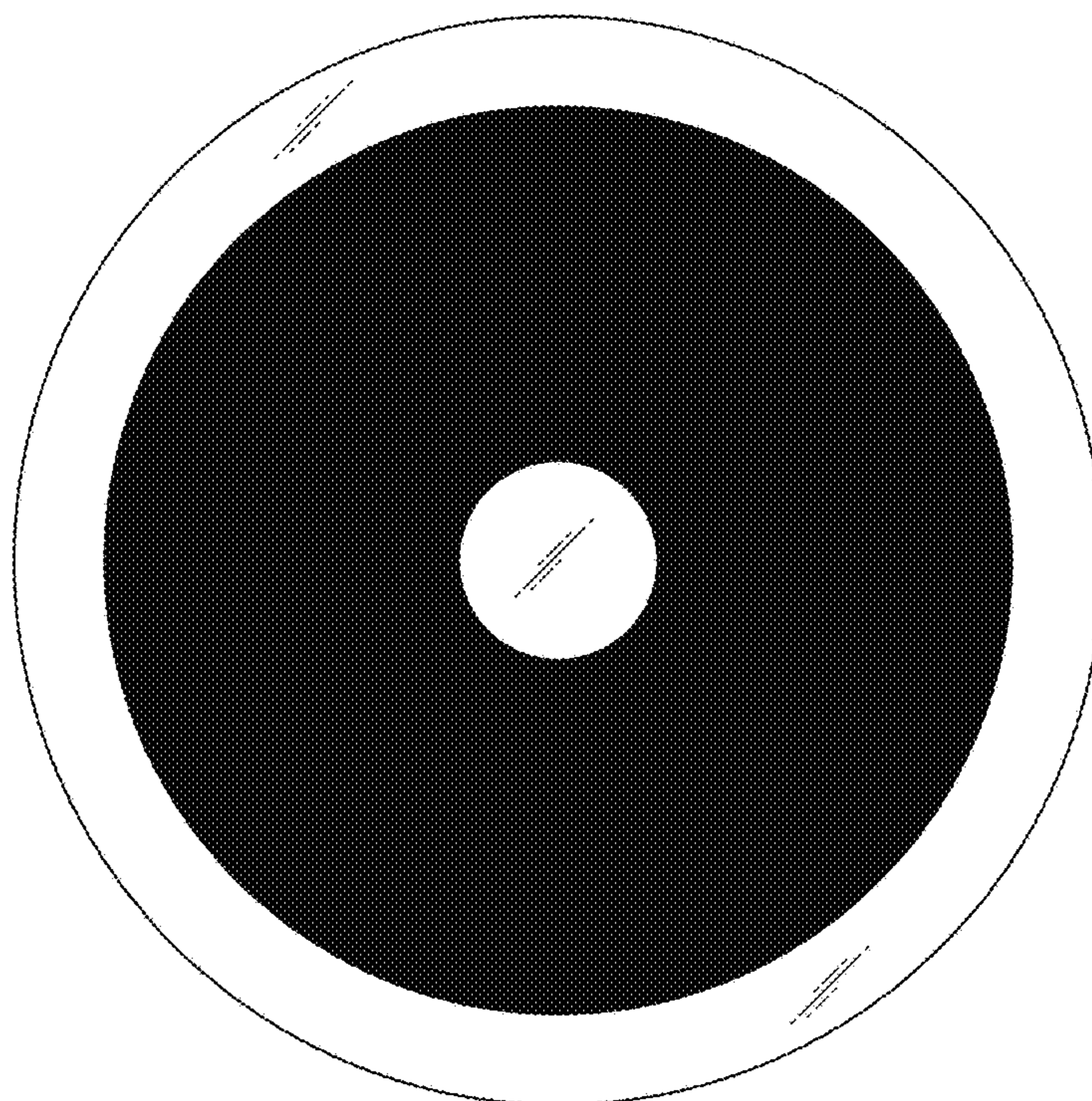


FIG. 7

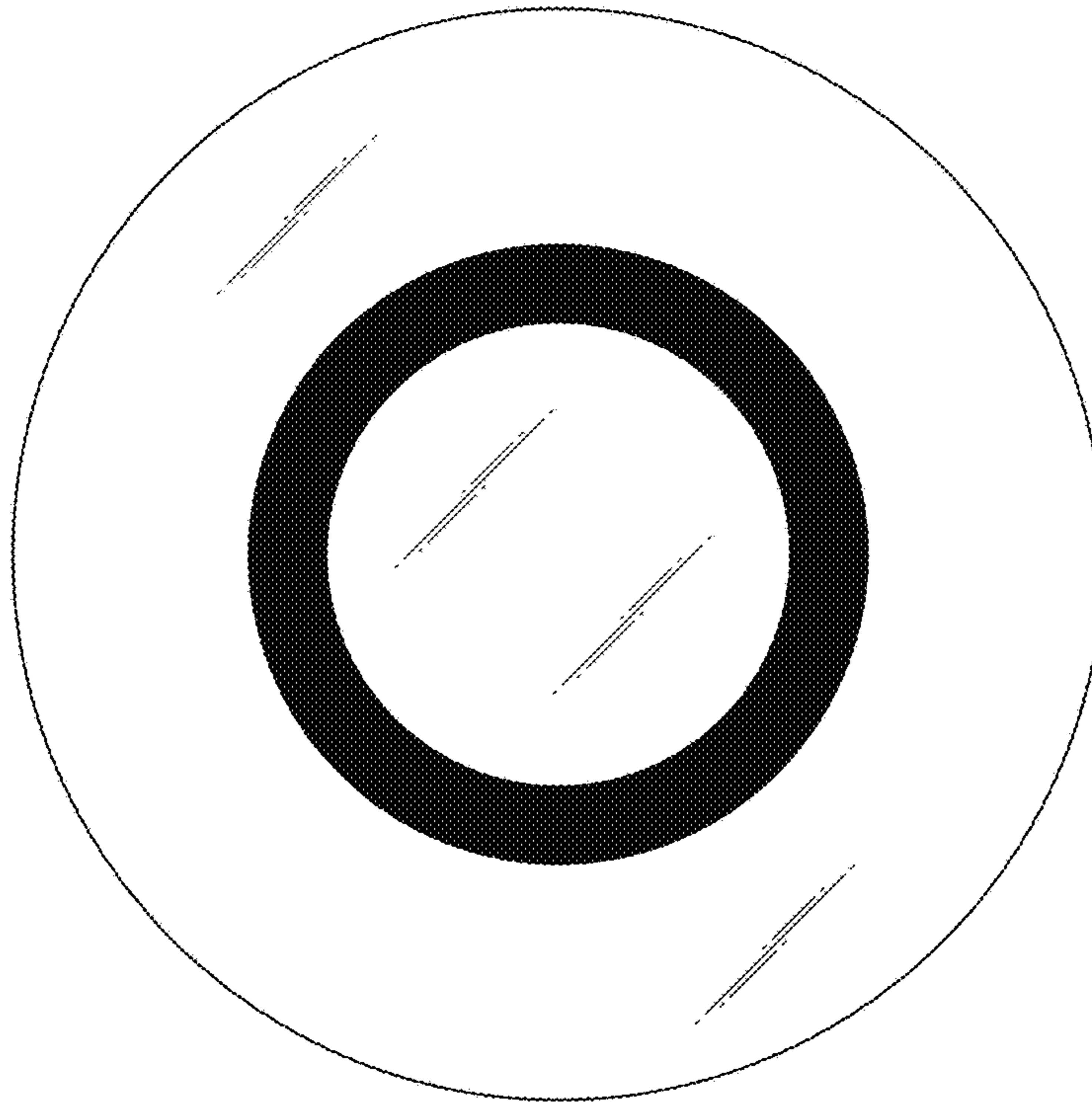


FIG. 8

